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ELECTRONICS INDUSTRIES®

**IPC-2251**

# **Design Guide for the Packaging of High Speed Electronic Circuits**

Developed by the IPC-2251 Task Group (D-21a) of the High Speed/  
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Users of this publication are encouraged to participate in the  
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# Design Guide for the Packaging of High Speed Electronic Circuits

## 1 GENERAL

**1.1 Purpose** The object of this document is to provide guidelines for the design of high-speed circuitry. The subjects presented here represent the major factors that may influence a high-speed design. This guide is intended to be used by circuit designers, packaging engineers, circuit board fabricators, and procurement personnel so that all may have a common understanding of each area.

**1.2 Scope** The goal in electronic packaging is to transfer a signal from one device to one or more other devices through a conductor. Considerations include electrical noise, electromagnetic interference, signal propagation time, thermo-mechanical environmental protection, and heat dissipation. High-speed designs are defined as designs in which the interconnecting properties affect circuit function and require consideration. Every electrical concept has relevant physical implementation data and limitations provided to match the electrical and mechanical relationships. This guideline presents first order approximations for each of the subject areas covered. If more detail is required, the papers presented in the bibliography may provide more detailed supplemental data. Since most high speed design requires signal intergity and EMI techniques, often field solvers, signal integrity simulation tools, EMI/EMC simulation programs may be required for resolving design challenges. Many PWB layout design tools include these tools as options to their programs. These simulators are driven by SPICE, IBIS, or other models. References to manufacturers of these tools may be found on the IPC Web site ([www.ipc.org](http://www.ipc.org)).

### 1.3 Symbology, Terms and Definitions

#### 1.3.1 Symbology

Symbol	Description
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ABT	Advanced Bipolar-CMOS Technology
AC	Advanced CMOS
AC	Alternating Current (Time varying current)
ACQ	Advanced CMOS Quiet
ACT	Advanced CMOS TTL Compatible
ACTQ	Advanced CMOS TTL Compatible Quiet
AGP	Advanced Graphics Port Logic
AHC	Advanced High-Speed CMOS
AHCT	Advanced High-Speed CMOS TTL Compatible

ALS	Advanced Low Power Schottky Technology
AS	Advanced Schottky Technology
BCT	Bipolar-CMOS Technology
CMOS	Complimentary Metal Oxide Semiconductor
COB	Chip-On-Board
CTE	Coefficient of Thermal Expansion
CTE <sub>XY</sub>	X and Y-Axis Coefficient of Thermal Expansion
CTE <sub>Z</sub>	Z-Axis Coefficient of thermal expansion
CTT	Center Tap Terminated Logic
DC	Direct Current
DIP	Dual In-line Package
DWB	Discrete Wiring Board
dV/dT	Delta Voltage/Delta Time (Edge Slew Rate)
ECL	Emitter Coupled Logic
EMI	Electromagnetic Interference
ESD	Electro-Static Discharge
F	Fast Bipolar Logic Technology
FR-4	Flame Retardant Level 4, Epoxy Glass Dielectric Material
GaAs	Gallium Arsenide Technology
GTL	Gunning Transceiver Logic
GTL+	Gunning Transceiver Logic Plus
HC	High-Speed CMOS Technology
HCT	High-Speed CMOS TTL Compatible
HL	High-to-Low Signal Edge Transition
HSTL	High-Speed Transceiver Logic
IBIS	I/O Buffer Information Specification
IBuf	Input Buffer
IC	Integrated Circuit
K <sub>B</sub>	Backward Crosstalk
K <sub>F</sub>	Forward Crosstalk
L <sub>G</sub>	Ground Plane Inductance
L <sub>H</sub>	Low-High Signal Edge Transition
L <sub>P</sub>	Power Plane Inductance
LVDS	Low Voltage Differential Signalling
LVEL	Low Voltage ECL
LVPECL	Low Voltage PECL
LVC MOS	Low Voltage CMOS Technology
LVT	Low Voltage Technology